

China IP Seminar

Mar. 3, 2010 (Wed) | Our office | Tokyo

Agenda

Time	Sessions	Speakers
12:30pm – 1:00pm	Arrival and Registration	
1:00pm – 1:05pm	Welcome and Introduction	Kenichi Nakayama (Tokyo)
1:05pm – 1:35pm	The new judicial interpretation on Patent Infringement Lawsuits	Shih Yann Loo (Hong Kong) Jing He (Beijing)
1:35pm – 2:05pm	Highlights on Inventor Reward and Inventor Remuneration Issues under the new Patent Implementing Rules	Jing He (Beijing)
2:05pm – 2:15pm	Coffee Break	
2:15pm – 2:45pm	The latest changes to the Design Patent Practice in the Amended Patent Law	Kenichi Nakayama (Tokyo)
2:45pm – 3:15pm	Standards related Patent Policy	Jing He (Beijing)
3:15pm – 3:45pm	Latest developments to Hong Kong Patent Litigation	Shih Yann Loo (Hong Kong)
3:45pm – 4:00pm	Q&A and Closing Remarks	Kenichi Nakayama (Tokyo)
4:00pm – 5:00pm	Networking	